




Charge-based deep level transient spectroscopy of B-doped and undoped polycrystalline diamond films

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ABSTRACT

The undoped and B-doped polycrystalline diamond thin film was synthesized by hot filament chemical vapor deposition and microwave plasma, respectively. The structural characterization was performed by scanning electron microscopy, X-ray diffraction and Raman spectroscopy. The electrical properties of synthesized diamond layer were characterized by dc-conductivity method and charge deep level transient spectroscopy. The B-doped diamond layers show higher sp^2/sp^3 ratios in comparison with that of undoped layers what can have an essential influence on the localized density of states associated with shallow hydrogen acceptor states what is reflected in the values of activation energies which reached the values of 38 meV for B-doped and 55 meV for undoped diamond layers, respectively. The existence of deep level traps, as, for example, associated with B-related acceptors, was not observed.

Introduction

Most of the physical properties of CVD diamond layers are very similar to that of natural diamonds and can find applications in many fields of science and technology such as a new material and can even replace the conventional materials used so far [1–3]. As it is well known, “as-grown” CVD diamond films are always hydrogen terminated, which generates, in

both undoped and B-doped, diamond layers p-type surface conductivity [4–6]. Due this effect, even undoped diamond layers can be used as electrode material in electrochemistry [7–9]. The role of hydrogen atoms in the diamond layers is investigated for many years and still remains far from full understanding [10, 11]. The hydrogen atoms are associated mainly with sp^2 carbon phase at diamond grain boundaries but can be also trapped in the bulk

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at structural defects (lattice defects and dislocations) [11, 12]. Tang et al. reported that the infrared active hydrogen is bonded also to the bulk diamond carbon atoms. The distribution of hydrogen in the diamond films is not uniform and may depend on preferential orientation of diamond microcrystals in diamond layer [13]. The type of the preferential orientation additionally determines crystalline quality of diamond layers [14].

The main goal of the present work is to study the electrical properties of boron-doped and undoped CVD diamond films. It is also important to show that the electrical conductivity is mainly dependent on H-related acceptor states. Charge-based deep level spectroscopy (QDLTS) used in this work allows to get information about the activation energies and capture cross sections for each uncompensated, electrically active defects in the diamond layers.

Experimental details

In present work, two techniques were used for polycrystalline diamond layers:

- The B-doped diamond layers were synthesized on (100) n-type silicon substrate by microwave plasma chemical vapor deposition (MP CVD) technique using SEKI Technotron AX5400S system. The process parameters were as follows: Total pressure was kept at 70 mbar and total flow of gases at 303 sccm, CH₄ concentration was 1 vol%, and the boron dopant precursor B₂H₆ was set at 0.05 and 0.15% in the working gas for Ax768-3 and Ax767-3 samples, respectively.
- The undoped diamond film (Dpk18) was synthesized on polished (111) n-type Si using hot filament chemical vapor deposition (HF CVD) technique [15]. As a working gas, the mixture of methanol vapor and hydrogen (2.75% in 97.25%, respectively) was used. The synthesis was carried out at a pressure of 40 mbar, and total flow working was kept at 100 sccm.

It should be mentioned that the MP and HF CVD methods are characterized by similar growth rates of diamonds layers, i.e., the differences in the activation processes in both methods are negligible [16].

In both cases prior to the growth process, substrates were cleaned in ultrasonic bath in acetone and 2-izopropanol for 5 min. Next, the substrates were

seeded using spin-coating of nanodiamond slurry as described elsewhere [17].

The diamond film morphology, grain's sizes and film thicknesses have been studied by scanning electron microscope (SEM), JEOL JSM-820 operating at a voltage of 25 kV, using LaB₆ Denka cathode. X-ray diffraction spectra were recorded by using DRON-4a, Θ -2 Θ XRD diffractometer. A Cu K α X-ray tube was operated at a voltage of 32 kV and 12 mA current. The Raman spectra were recorded at room temperature in back scattering geometry using Renishaw in Via Raman spectrometer with the 488 nm line from argon laser as excitation source.

Current–voltage characteristics of Al/diamond/n-Si/Al heterojunction were measured in the voltage range of –5 to +5 V using a voltage generator Elpan EG20 and Keithley 6485 Picoammeter. Measurements were taken for temperatures range from 190 K to RT (room temperature).

Q-DLTS measurements were taken in temperature range of 260–380 K, using homemade system in a typical configuration. As an excitation source, the laser light (405 nm) was used. The excitation pulse duration was controlled by Signal Recovery 197 Light Chopper.

Results and discussion

Figure 1 shows SEM photographs of the undoped (Dpk18) and B-doped (Ax768-3 and Ax767-3) diamond films. Both types of diamond layers show clear crystalline feature having very similar morphologies.

Average values of grain sizes for all layers estimated from the SEM photographs (using software SemAfore v.5.21) and are collected in Table 1. The diamond crystallites of undoped diamond layer are clearly bigger in comparison with that of boron-doped layers. This can be understandable because the thickness of Dpk18 layers is much bigger than other diamond layers. From the other hand, it is well known that the heavy boron doping spoils the diamond structure and, in consequence, leads to the decrease in crystallite's sizes [18]. Additionally, the B-doping leads to the essential increase in sp² carbon phase content in the layers as it is observed by Raman spectroscopy (Fig. 2 and Table 1).

The Raman spectra of the CVD diamond film (Fig. 2), in general, consist of sharp diamond peak

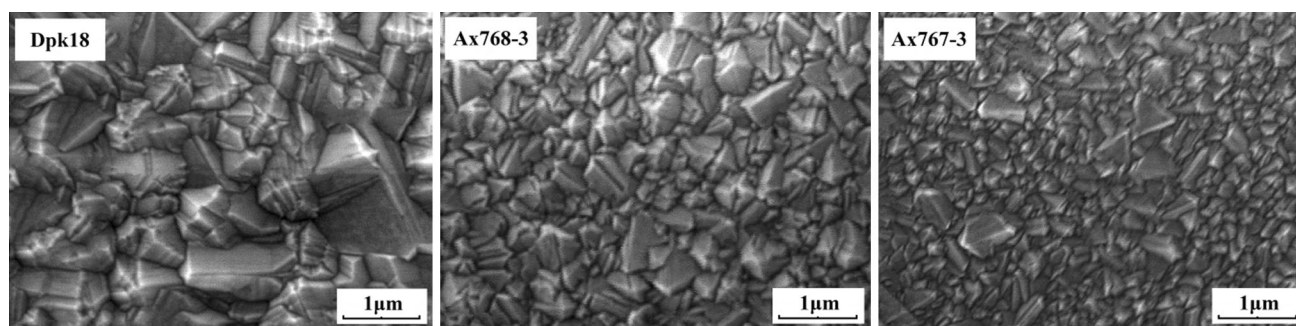


Figure 1 Morphology of obtained diamond films: undoped layer: Dpk18, B-doped layers Ax768-3 and Ax767-3 at the concentration level of B_2H_6 in the working gas: 0.05 and 0.15%, respectively.

Table 1 Quality parameters of obtained diamond layers

		Dpk18	Ax768-3	Ax767-3
B_2H_6	%	–	0.05	0.15
Average grain sizes (SEM)	μm	0.88	0.47	0.32
The thickness of layers	μm	7.5	2.5	2.5
sp^2/sp^3 ratio (f)	%	1.5	2.45	2.8
FWHM	cm^{-1}	7.9	11.2	10.7
Slope (m)	cm	5.4	23	28
The hydrogen content (H)	%	2.6	13.7	16.1
<i>Texture coefficient</i>				
$\langle 111 \rangle$	%	5.1	6.0	6.9
$\langle 220 \rangle$	%	74.6	29.5	30.8
$\langle 331 \rangle$	%	20.3	64.5	62.3

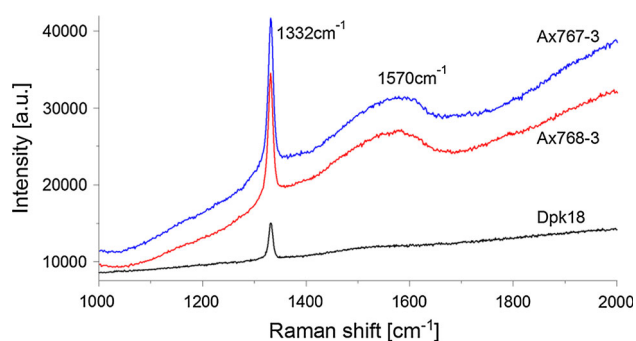


Figure 2 Raman spectra of B-doped (Ax767-3 and Ax768-3) and undoped (Dpk18) diamond layers.

with FWHM in the range of 8–12 cm^{-1} and broad band, called G-line, peaked at 1570 cm^{-1} [19].

Additionally each Raman spectrum is characterized by photoluminescence background having different slopes m . The FWHM of diamond Raman line is commonly used as a measure of the diamond quality [19]. The Raman spectrum of the undoped diamond film contains sharp diamond line centered at 1331.9 cm^{-1} and is characterized by an FWHM having value of about 8 cm^{-1} , which is essentially narrower in

comparison with that observed for B-doped diamond layers (Fig. 2 and Table 1). It means that the undoped diamond layers are better quality in comparison with B-doped diamond layers what is in good agreement with morphologies presented in Fig. 1.

The numerical decomposition of the Raman spectra into pure diamond and pure amorphous carbon components allows us to characterize the diamond quality by a method described elsewhere [20]. Results of Raman spectroscopy measurements are collected in Table 1, where sp^2/sp^3 is the ratio of nondiamond to pure diamond carbon fracture in the diamond layer.

The diamond Raman peaks in Fig. 2 are superimposed on a broad luminescence background. It is known that broad luminescence background arises from hydrogenated amorphous carbon admixture in diamond layers and its slope m can be used to determine the hydrogen content. The hydrogen content, associated with amorphous carbon at the diamond grain boundaries, can be calculated from the slope m of photoluminescence background of the Raman spectrum (Fig. 2) according to the empirically derived following equation [21]:

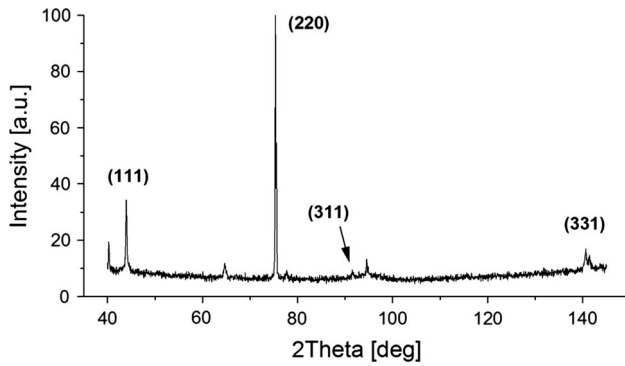


Figure 3 Normalized diffraction spectra of undoped layer Dpk28.

$$H[\%] = 21.7 + 16.6 \log\left(\frac{m}{I_G} [\mu m]\right) \quad (1)$$

where I_G is integral intensity of Raman G-band.

The slopes m and hydrogen concentrations in amorphous carbon phase admixture, which is small

fraction of diamond layers, are collected in Table 1. The m values (Table 1) clearly indicate that hydrogen concentrations in B-doped diamond layers are much higher in B-doped layers what should have an influence on H-related acceptor concentrations in diamond layers.

B-doping not only influences hydrogen concentration but also can be responsible for preferred orientation of diamond microcrystallites which can be estimated from XRD diffraction measurements. Typical XRD spectrum is shown in Fig. 3.

The preferred orientations of crystallites in the layers were estimated using texture coefficient, $TC_{(hkl)}$ [22, 23]. The results are collected in Table 1.

The texture coefficient (Table 1) for the $\langle 111 \rangle$ direction, for all the studied layers is very similar. The differences are observed for other crystalline directions, as, for example, for the undoped layer

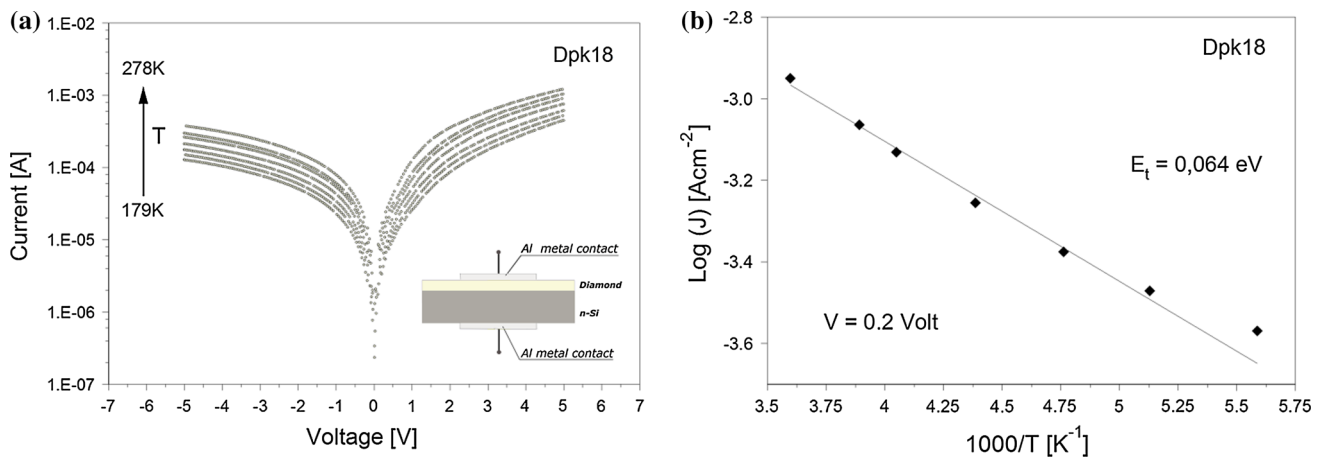


Figure 4 **a** Semi logarithmic chart I-V-T for sample Dpk18 (the *inset* shows an electrode configuration), **b** the Arrhenius plot.

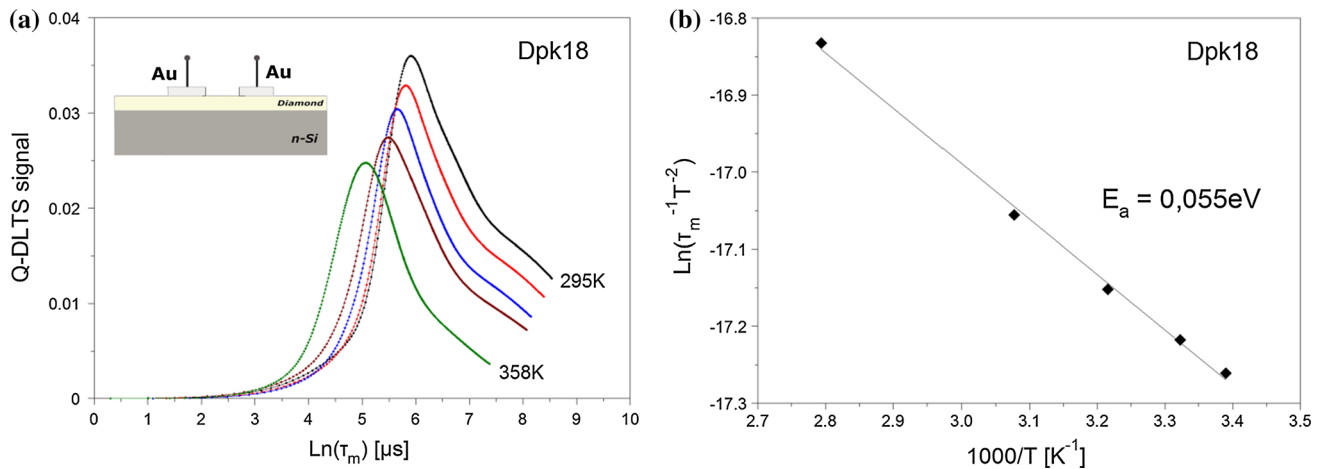


Figure 5 **a** Q-DLTS spectra for sample Dpk18, **b** Arrhenius plot for this sample.

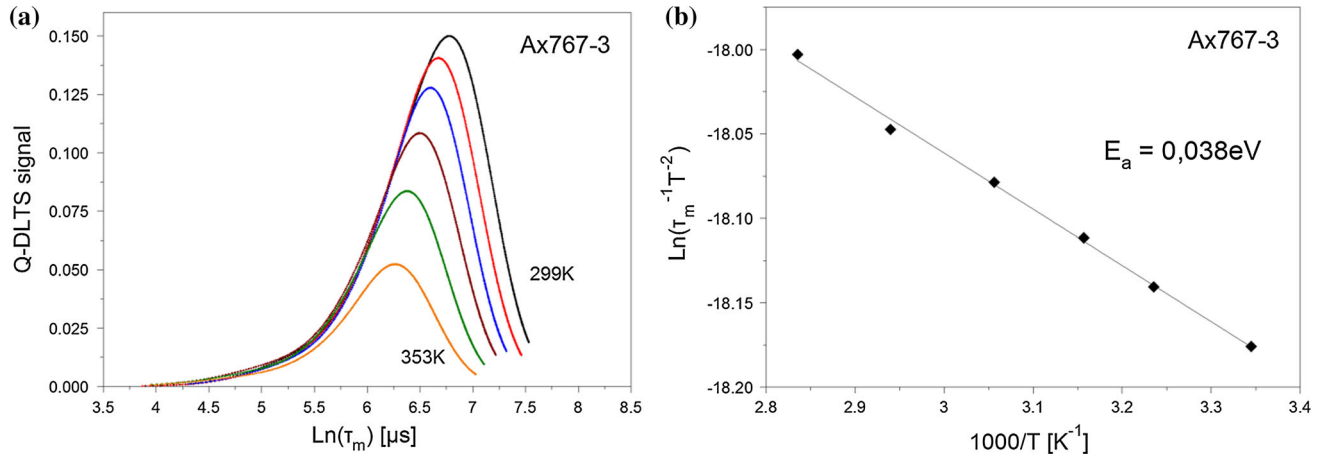


Figure 6 a Q-DLTS spectra for sample Ax767-3, b Arrhenius plot for this sample.

predominate crystallites of $\langle 220 \rangle$, and for boron-doped layers of $\langle 331 \rangle$ orientations.

It is expected that structural properties will govern the electrical properties of diamond layers. Some properties, as, for example, activation energies measured using diamond/n-Si heterojunction, can be determined on the basis of thermionic emission model [24]. But this model does not include the effects of the series resistance of the diamond bulk. If applied bias is higher than barrier height (high forward biases), the nature of the bulk conduction reveals. When the number of injected carriers exceeds the number of thermal carriers (available in the diamond bulk), the charge transport switches from an ohmic character ($I \sim V$), to a space-charge-limited current (SCLC) ($I \sim V^2$), described by the Mott-Gurney law [24, 25].

Figure 4a shows a I - V - (T) graph for Dpk18, i.e., undoped diamond sample measured in temperatures between ca. 179 K and RT.

As one can see the heterostructure has slightly straightening properties what confirms earlier reports of the p-type semiconducting nature of the undoped diamond layers [4, 5]. At low voltages, the conduction mechanism has an ohmic character described by formula (1) [26]:

$$J = N_V q \mu_p \frac{V}{d} \exp\left(-\frac{E_a}{kT}\right), \tag{2}$$

where N_V —valence band density of state (10^{19} cm^{-3} for diamond), q —elementary electric charge, μ_p —the mobility of dominant charge carrier, V —voltage, d —sample’s thickness, k —Boltzmann constant.

From the Arrhenius plot, i.e., $\log(J)$ versus $1/T$ (Fig. 3b), the activation energy for undoped diamond

layer was estimated using formula (2). The obtained activation energy equal to 0.064 eV is rather small and indicates on shallow energy states.

The useful method to study the trapping centers is deep level transient spectroscopy (Q-DLTS) [27]. In this method, the trapped charge transient process is measured by the voltage or light stimulation. The Q-DLTS method used in present work is described in details elsewhere [27–29].

If t_1 and t_2 will be the times counted from the beginning and the end of the discharge, then the measured value of the Q-DLTS signal can be write as: $\Delta Q = Q(t_2) - Q(t_1)$. The charge ΔQ flowed through the circuit during the time period $\Delta t = t_2 - t_1$ is measured as a function of several parameters, including the rate window: $\tau_m = (t_2 - t_1) / \ln(t_2/t_1)$.

If the ratio $t_2/t_1 = \alpha$ and will be kept constant, then τ_m will be equal to $\tau_m = t_1(\alpha - 1) / \ln \alpha$, and the maximum of the functional dependence of $\Delta Q(\tau_m)$ can be used to determine the trapping (donor or acceptor-like) center parameters $e_{n,p}$. Taking $\alpha = 2$, i.e., $\tau_m = t_1 / \ln 2$, we will have [29]:

$$e_{n,p} = \tau_m^{-1} = \sigma_{n,p} \Gamma_{n,p} T^2 \exp\left(-\frac{E_a}{kT}\right), \tag{3}$$

where $\Gamma_{n,p} = 2 \times \sqrt{3} (2\pi/h^2)^{3/2} k^2 m_{n,(p)}^*$, E_a is activation energy, $\sigma_{n,p}$ is capture cross section, T is the temperature, k is the Boltzmann constant, and $m_{n,(p)}^*$ is the effective mass of the electron (hole).

The activation energy E_a and capture cross section $\sigma_{n,p}$ can be obtained from Arrhenius dependence, i.e., $-\ln(\tau_m^{-1} \times T^{-2})$ versus T^{-1} .

The Q-DLTS spectra registered for Dpk18 and Ax767-3 samples are shown in Figs. 5a and 6a. The

inset (Fig. 5a) shows an electrode configuration applied for measurements of Q-DLTS spectra.

The results shown in Fig. 4b allow to estimate activation energies E_a using the Arrhenius plot according to Eq. 3 as it is shown in Fig. 5b.

The activation energy determined by Q-DLTS for sample Dpk18 (Fig. 5b) is in a good agreement with the value calculated by the DC measurements (Fig. 4b). Such shallow defects can be associated with chemically bonded hydrogen atoms which create acceptor states just above the top of valence band [30].

The values of activation energies obtained for diamond layers studied within the present work have very similar values. For the sample, Dpk18 amounts to $E_a = 0.055$ eV, for Ax768-3 $E_a = 0.046$ eV, and for Ax767-3 (Fig. 6) $E_a = 0.038$ eV, suggesting a similar origin. For all samples, captured cross section $\sigma_{n,p}$ was approximately 1×10^{-21} – 1×10^{-23} cm², which are characteristic of point defects such as vacancies or dangling bonds [29].

B-related acceptor states have much larger activation energies [31], and their contribution to the electrical properties is not directly observed in measured, in this work, temperature range.

However, as it is seen from Fig. 2 and Table 1 the boron doping has an essential influence on the structural properties of diamond layers and especially on the concentration of sp² hybridized carbon phase and H-concentration and thus influences the electrical properties of diamond layers.

The highest sp²/sp³ ratio, the highest chemically bonded hydrogen concentration [4] which leads to higher hydrogen acceptor density of states [32] and can cause the shift of Fermi energy toward the top of valence band. Finally, the activation energies observed for B-doped diamond layers show lower values in comparison with that observed for undoped layer. Both types of layers show similar conductivity character which can be due to the presence of shallow hydrogen acceptor states.

Conclusions

The diamond layers were synthesized by using two methods: HF CVD method for undoped diamond layers and MP CVD for B-doped layers, respectively. The structural properties including diamond quality, crystallite's sizes and preferential orientations of

B-doped and undoped diamond layers show essential differences both in diamond quality (FWHM Raman band) as in the ratios of sp²/sp³ and H-concentrations.

The activation energies and captured cross section were estimated on the basis of QDLTS measurements. The activation energies for B-doped are clearly lower (0.038 eV) in comparison with those of estimated for undoped layer (0.055 eV).

These results are in agreement with the results obtained in DC measurements. The obtained results (small activation energies) are characteristic for hydrogenated CVD diamond layers. Within the specified temperatures range, the existence of deep level traps, associated also with B acceptors, was not observed.

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Compliance with ethical standards

Conflict of interest The authors declare that they have no conflict of interest.

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